

PATENTS

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

APPLICANT: WEI, Kung-Hwa et al ATTY DOCKET: BA-22878

SERIAL NO. : 10/828,435

FILED : April 20, 2004

FOR : COVALENTLY BONDED POLYHEDRAL OLIGOMERIC

SILSESQUIOXANE/ POLYIMIDE NANOCOMPOSITES AND

PROCESS FOR SYNTHESIZING THE SAME

SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT

MAILSTOP: AMENDMENT

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

SIR:

Supplemental to the Information Disclosure Statement filed June 7, 2004, applicants enclose Form PTO-1449 and a copy of six (6) references discussed in the specification on pages 2 and 4. It is respectfully requested that the foregoing Supplemental Information Disclosure Statement (IDS) be incorporated into the official file of the present patent application. Because this Supplemental IDS is being filed before a first Office Action on the merits, it is believed that no fee is required. However, if a fee should be required for this IDS, the Commissioner for Patents and Trademarks is hereby authorized to charge any required fee, or to credit any overpayment to Deposit Account No. 03-2468.

Respectfully submitted,

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I hereby certify that this document is being deposited with the U.S. Postal Service on June $\frac{\cancel{VO}}{}$, 2004, as first class mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.

Maria Guastella

FORM PTO-1449 (REV. 7-80)		U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE				ATTY. DOCKET NO. : BA-22878			SERIAL NO. 10/828,435			
LIST OF REFERENCES CITED BY APPLICANT						APPLICANT: Kung-Hwa WEI ET AL						
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